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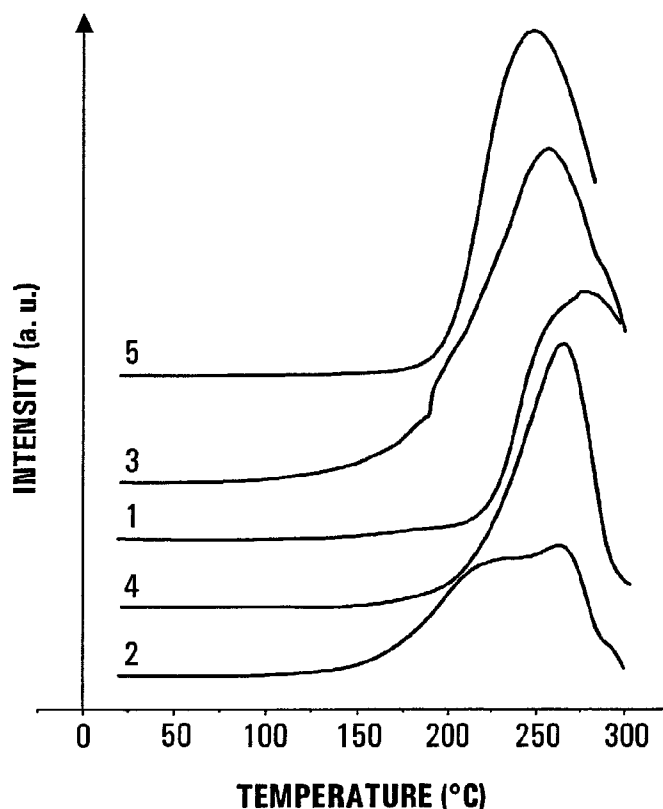
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(54) Title: METHOD FOR REVERSIBLE STORAGE OF HYDROGEN AND MATERIALS FOR HYDROGEN STORAGE



(57) Abstract: Metal-N-based or metal-loid-N-based materials absorb a substantial amount hydrogen and are useful as hydrogen storage materials for various applications such as hydrogen fuel cell technology.

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